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PATENT
Attorney Docket No. 401479

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Art Unit: 1742

IZUO et al.

Examiner: D. Valentine

Application No.: 10/009,521

Date of Allowability: November 21, 2003

Filed: December 11, 2001

Confirmation No.: 4369

For: METHOD AND APPARATUS
FOR RADIATION ASSISTED
ELECTROCHEMICAL ETCHING
AND ETCHED PRODUCT

RESPONSE TO NOTICE OF DRAWING INCONSISTENCY

Mail Stop Issue Fee
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

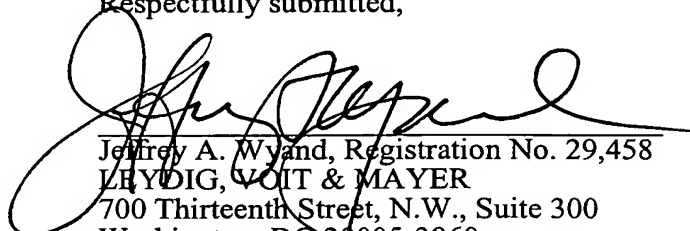
In response to the Notice of Drawing Inconsistency, Applicants request a specification amendment and a substitution of the attached replacement drawing sheet. The replacement drawing sheet is submitted to be consistent with the drawing amendment that accompanied the filing of the patent application and was part of a Preliminary Amendment. The specification was amended to conform to this drawing amendment but no replacement drawing sheet had been submitted because the Examiner indicated that the original drawings were satisfactory. The oversight in failing to submit the readily available drawing sheet is regretted.

The Notice made reference to Figure 2E but did not clearly indicate the issue. It is apparent that there is no Figure 2E in the patent application. Therefore, the incorrect brief description of the drawings at page 10 of the patent application is corrected in the accompanying specification amendment.

In re Appln. of IZUO et al.
Appln. No. 10/009,521

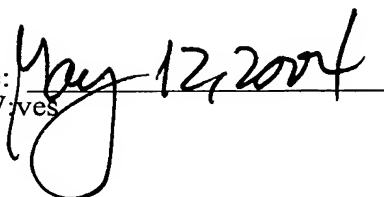
Entry of the replacement drawing sheet and of the specification amendment so that this patent application can be issued as a patent is respectfully requested.

Respectfully submitted,



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Date:
JAW:ves



May 12, 2004

SPECIFICATION AMENDMENTS

Replace the paragraph beginning at page 10, line 14 with:

Figs. 2A to ~~2E~~ 2D are drawings, each ~~of which~~ showing a cross sectional shape of a pore formed in the silicon substrate, ~~a~~ diameter of the pore, and ~~an~~ illumination in Experiment 2;